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Response  
D Smalls-LoganI HEREBY CERTIFY THAT THIS CORRESPONDENCE IS BEING  
FAXED TO: THE COMMISSIONER FOR PATENTS, WASHINGTON,  
D.C. 20231, ON

Date of Deposit: December 30, 2002

Name of Person Faxing: Colleen J. Dew

Signature:

Colleen J. Dew

1-9-03

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE	
In Re Application of: M. Khare <i>et al.</i>	December 30, 2002
	Examiner: Fernando L. Toledo
Serial No. 09/809,663 Filing Date: March 15, 2001	Group Art Unit: 2823
Title: METHOD FOR IMPROVED PLASMA NITRIDATION OF ULTRA THIN GATE DIELECTRICS	IBM Corporation 2070 Route 52 Dept. 18G, Bldg. 300-482 Hopewell Junction, N.Y. 12533

RESPONSE UNDER 37 C.F.R. § 1.111The Commissioner for Patents  
Washington, D.C. 20231

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TECHNOLOGY CENTER 2800

Sir:

In response to the non-final Office Action mailed November 1, 2002, Applicants respectfully request entry of the following remarks into the file of the above-identified application.